

Wafer-Scale LSPR Substrate: Oblique Deposition of Gold on a Patterned Sapphire Substrate

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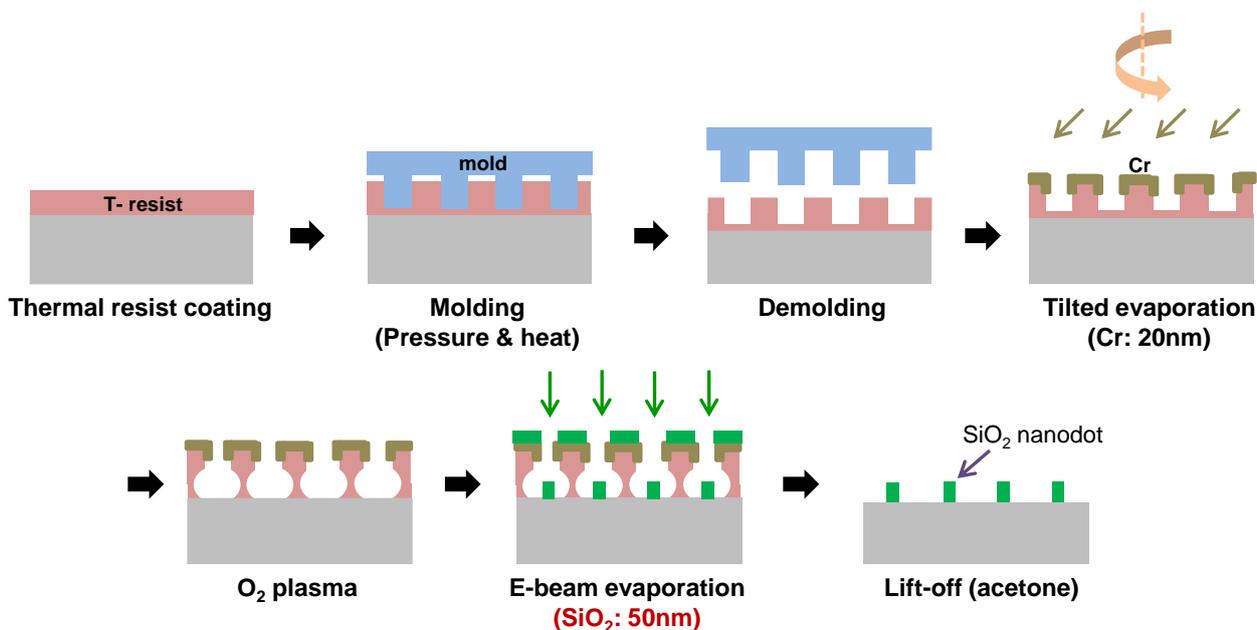


Figure S1. Schematic of the formation of a SiO₂ nanodot array on a sapphire wafer using nanoimprint lithography.

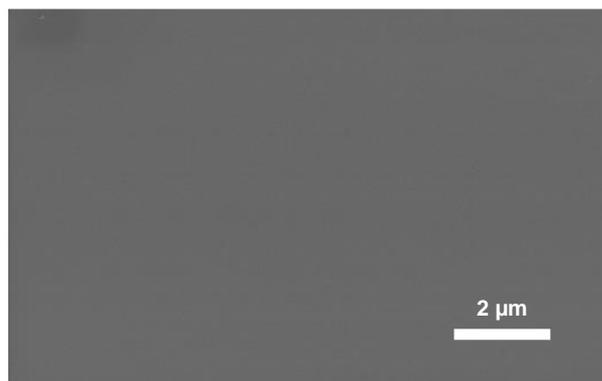


Figure S2. SEM image of the SiO₂ nanodot (not annealed)-patterned sapphire wafer after the wet etch. This image indicates that SiO₂ nanodots were etched by H₂SO₄ and H₃PO₄, which was not able to act as hard masks.

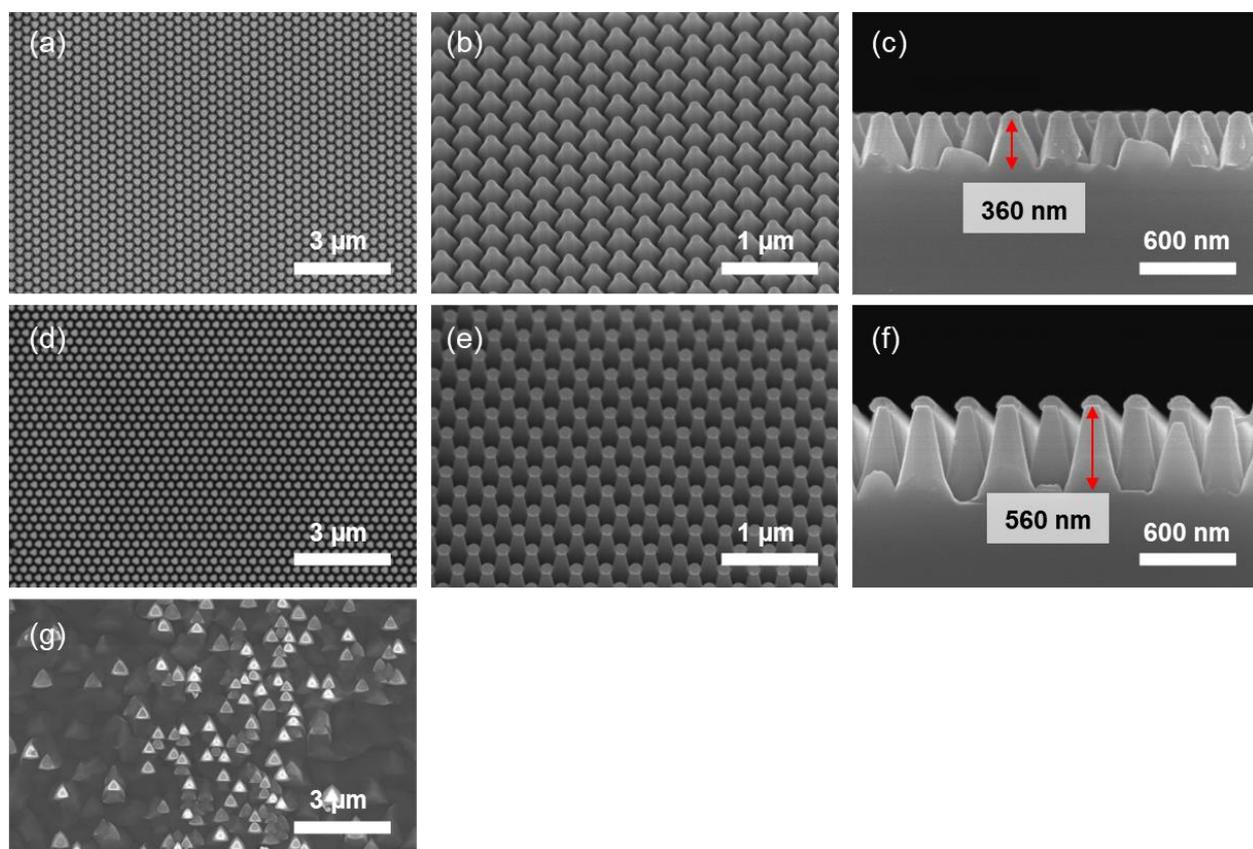


Figure S3. SEM images of a PSS (wet etch solution: H₂SO₄:H₃PO₄= 3:1 (v/v)): etch temperature: (a-c) 310°C, (d-f) 330°C, and (g) 350°C. (a),(d),(g) Top, (b),(e) 45° tilted, and (c),(f) side views.

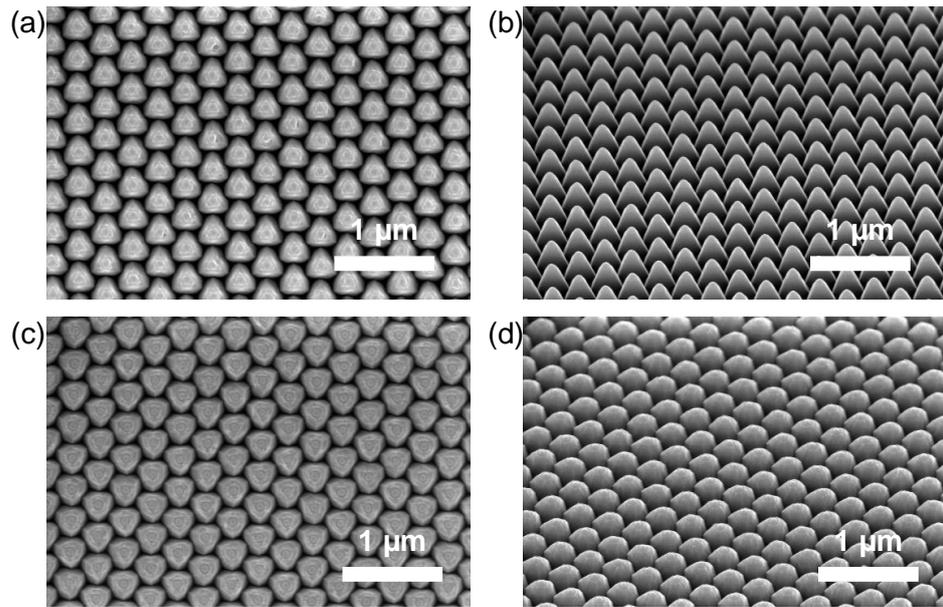


Figure S4. SEM images after the second wet etch of PSS. Before the second wet etch, SiO₂ hard masks were eliminated using a buffered oxide etch solution. Conditions for the second wet etches were (a), (b) H₂SO₄:H₃PO₄ = 1:1 and (c), (d) H₂SO₄:H₃PO₄ = 1:3, at 310°C and 40 min for both. ((a) and (c): top views, (b) and (d): 45° tilted views).

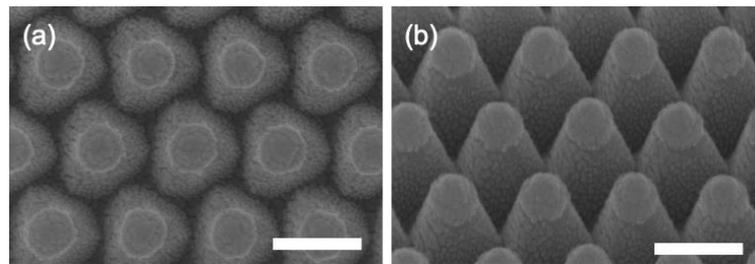


Figure S5. SEM images after vertical deposition of Au onto a PSS ((a): top view, (b): 45° tilted view). Scale bars in the images are 300 nm.

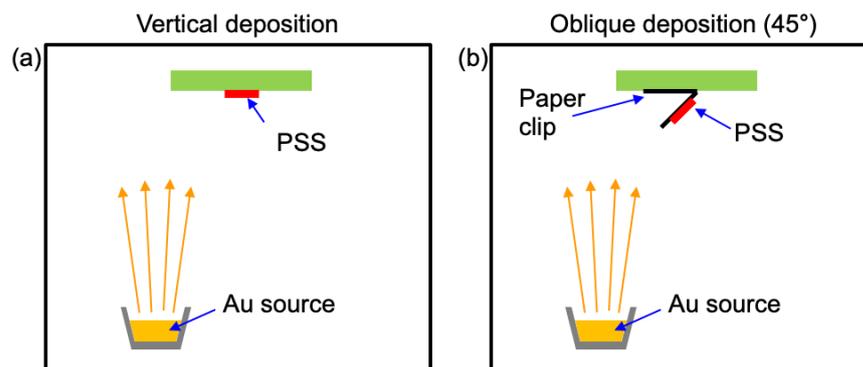


Figure S6. Schematic illustration of (a) vertical deposition and (b) oblique deposition of Au on PSS.

Figure S7. Absorbance and SEM images of Au/PSS where Au was deposited at the angle of (a) 0°, (b) 30°, (c) 45°, and (d) 60° (Note that (i), (ii), and (iii) indicate absorbance data, top-view SEM images, and tilted-view, 45°, SEM images, respectively.).

Table S1. LSPR-shift observation of obliquely deposited Au on PSS when exposed to biomolecules.

Adding sequence	1	2	3	4
Added molecule	Biotin-HPDP	STA	Biotin-BSA	STA

LSPR peak (nm)	782	784	786	788
Shift (Δ)	-	+2	+2	+2